AMENDMENTS TO THE CLAIMS

1. (Currently amended) A method of preparing [[a]] circuit layout data for the

<u>application of optical and process correction (OPC), comprising:</u>

receiving a description of data that represents a layer of an integrated circuit that is

defined as a number of polygons;

fragmenting a polygon into a number of edge segments by defining a number of

<u>fragmentation endpoints</u> that extend around the perimeter of the polygon;

defining control sites for the edge segments;

computing a simulation of the layout that estimates light intensity values in an area

corresponding to a control site of at least one of the edge segments;

calculating a curvature of the light intensity in the area of in a direction parallel to the at

least one edge segment at the control site; and

using the curvature of the light intensity to refragment the edge segments of adjust the

number of fragmentation endpoints on the perimeter of the polygon.

2. (Currently amended) The method of Claim 1, wherein the refragmentation of the

edge segments is performed by number of fragmentation endpoints is adjusted by:

increasing the density of the edge segments adding one or more fragmentation endpoints

to a polygon if the curvature of the light intensity calculated at a position corresponding to a

control site for an edge segment is greater than a predetermined threshold.

3. (Currently amended) The method of Claim 1, wherein the refragmentation of the

edge segments is performed by number of fragmentation endpoints is adjusted by:

calculating a curvature of the light intensity at a position corresponding to the control site

and in the area of in a direction parallel to an adjacent edge segment; and

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decreasing the density of the edge segments removing one or more fragmentation endpoints from the perimeter of the polygon if the curvature of the light intensity calculated for at a position of the control sites defined for adjacent edge segments is less than a predetermined

threshold.

4. (Canceled)

5. (Currently amended) A computer readable storage medium including a sequence

of program instructions recorded thereon that, when executed by one or more processors, cause

the one or more processors to implement the method of any of Claims 1-4 Claims 1-3.

6. (Withdrawn) A mask/reticle used for the creation of one or more layers of an

integrated circuit that is created using the method of any of Claims 1-4.

7. (Withdrawn) A file describing a layer of an integrated circuit that has been

prepared using the method of any of Claims 1-4.

8. (Currently amended) A method for preparing data that describes a layout of an

integrated circuit by:

fragmenting polygons that describe structures of an object to be created via

photolithography comprising:

performing an initial fragmentation that divides a polygon into a number of edge

segments that extend around the perimeter of the polygon;

defining control sites for the edge segments;

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computing a simulation of how the structures will be printed a curvature of an image intensity at a location on a wafer corresponding to a control site in a direction parallel to an edge segment under defined process conditions; and

using the results of the simulation to adjust the fragmentation of the polygons polygon to add fragmentation endpoints in areas where the curvature of the image intensity is greater than a predetermined amount and/or to remove fragmentation endpoints where the curvature of the image intensity is less than a predetermined amount.

- 9. (Canceled)
- 10. (Canceled)
- 11. (Canceled)
- 12. (Currently amended) A computer readable storage medium that stores a sequence of program instructions that when executed by one or more computers cause the one or more computers to implement the method of any of Claims 8 11 Claim 8.
- 13. (Withdrawn) A file describing objects to be created via photolithography that has been prepared using the method of any of Claims 8-11.